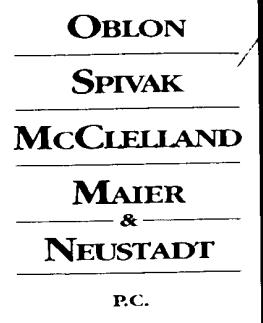




Docket No.: 212020US99



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P.C.

ATTORNEYS AT LAW

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

RE: Application Serial No.: 09/911,444

Applicants: Tomasz KLOSOWIAK, et al.

Filing Date: July 25, 2001

For: STRUCTURE AND METHOD FOR FABRICATING
SEMICONDUCTOR STRUCTURES AND
DEVICES WITH OPTICAL PROCESSING
LAYERS UTILIZING THE FORMATION OF A
COMPLIANT SUBSTRATE FOR MATERIALS
USED TO FORM THE SAME

Group Art Unit: 2826

Examiner: MONDT, J.P.

SIR:

Attached hereto for filing are the following papers:

**RESPONSE TO RESTRICTION REQUIREMENT; REQUEST FOR EXTENSION OF TIME
(THREE-MONTH)**

Our check in the amount of \$920.00 is attached covering any required fees. In the event any variance exists between the amount enclosed and the Patent Office charges for filing the above-noted documents, including any fees required under 37 C.F.R. 1.136 for any necessary Extension of Time to make the filing of the attached documents timely, please charge or credit the difference to our Deposit Account No. 15-0030. Further, if these papers are not considered timely filed, then a petition is hereby made under 37 C.F.R. 1.136 for the necessary extension of time. A duplicate copy of this sheet is enclosed.

Respectfully submitted,

OBLON, SPIVAK, McCLELLAND,
MAIER & NEUSTADT, P.C.

Richard L. Treanor
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DOCKET NO.: 212020US99

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

IN RE APPLICATION OF:

: GROUP ART UNIT: 2826

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RESPONSE TO RESTRICTION REQUIREMENT

ASSISTANT COMMISSIONER FOR PATENTS
WASHINGTON, D.C. 20231

SIR:

Responsive to the Restriction Requirement dated March 12, 2002,
Applicants elect Group I, Claims 1-13.

REMARKS

The claims in this case have been restricted into two Groups: Group I, Claims 1-13 and Group II, Claims 14-17. Applicant has elected Group I. However, the, Restriction Requirement is traversed.

The Office Letter characterizes the restricted claims as being related as